

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	0	plate and (phase adj shift) and (polygonal adj etch adj window) and (electromagnetic adj wave)	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/07/24 17:43
L2	0	plate and (phase adj shift) and (polygonal near5 etch\$3 near5 window) and (electromagnetic adj wave)	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/07/24 17:44
L3	12	plate and (phase adj shift) and polygonal and (electromagnetic adj wave)	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/07/24 17:51
L4	0	((integrated adj circuit) or IC) and substrate and (phase adj shift) and polygonal and (electromagnetic adj wave)	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/07/24 17:51
L5	10	substrate and (phase adj shift) and polygonal and (electromagnetic adj wave)	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/07/24 17:51
L6	2	5 not 3	USPAT; EPO; JPO; DERWENT	OR	OFF	2005/07/24 17:52